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Optical and electrical performance of 5 μm InAs/GaSb Type-II superlattice for NOx sensing application

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1 Highlights

- 2 Environmental pollutant NOx is the greatest global challenge confronting humanity
- $_{\rm 3}$ $_{\rm Optical properties and electrical properties of 5 <math display="inline">\mu$ InAs/GaSb T2SL photodiode
 - Higher operating temperature (200 -300 K), G-R and TAT are dominant
 - Surface leakage contributes to G-R dark current in T2SL photodiodes
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Journal Prevention

- 1Optical and electrical performance of 5 μm InAs/GaSb Type-II superlattice for NOx2sensing application
 - M Kesaria, D Alshahrani, D Kwan, E Anyebe and V Srivastava
- 3 4
- 5

Abstract

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6 We report on the optical and electrical performance of optimized InAs/GaSb type-II superlattice (T2SL). The optical quality of optimal T2SL is compared with InAs/InAsSb T2SL. 7 8 Dominant photoluminescence (PL) peak at around 5.3µm at 77 K was obtained for the Ga-9 based samples with an intensity which is less sensitive to changes in temperature compared 10 to the Ga-free SL. The PL peak intensity of the Ga-based T2SL with an intentional InSb layer 11 was found to be less responsive to changes in temperature and tuned to longer wavelength suitable for NO_x sensing. Current-Voltage modelling of the fabricated Photodiode 12 demonstrates that at a temperature of 110K, generation recombination (G-R) and trap 13 assisted tunnelling (TAT) currents dominates below and above an applied bias of ~0.2 V 14 15 respectively. However, at higher operating temperature (200 -300 K), diffusion current is prevalent at low applied bias while G-R and TAT are dominant at high applied bias. 16

17

18 **Keywords:** A. InAs/GaSb, A. Type-II superlattice, D. 5 μm, D. photodiodes, D. NO_x sensing

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20 Introduction

Environmental pollution is one of the greatest challenges confronting humanity globally. 21 Nitric oxide (NO) and nitrogen dioxide (NO₂), which are collectively referred to as NOx, are 22 23 highly poisonous and detrimental to air quality and a primary source of air pollution, contributing to the formation of smog and acid rain[1]. NOx is a toxic gas produced during 24 25 combustion of fossil fuels in power plants and automobile engines as well as during lightning 26 in thunderstorms and contributes to numerous functions in the human body where it is 27 produced in inflammatory processes [2-4]. Traditional gas detection instruments, such as chemiresistive sensors, require direct contact with the target gas, greatly limiting their 28 29 practical use for scanning of large areas or multiple sites. However, by making use of the

unique absorption spectra of NOx gases, optical gas detectors can provide real time imaging
in which target gases appear as highlighted clouds. Therefore, non-contact, photodetectorbased sensors are both faster and more practical than conventional gas detectors for most
industrial applications.

5 Highly sensitive photodetectors operating in the 5.1 - 5.6 µm spectra band at high temperature are urgently required for low-cost detection of NOx gas. Although, Mercury 6 Cadmium Telluride (MCT) and Quantum Well Infrared Photodetectors (QWIPs) are well-7 8 established technologies in mid-infrared (MWIR) for photodetection. They require cryogenic cooling systems to achieve high signal-to-noise ratio at high temperatures. In addition, MCT 9 10 is plagued with high material toxicity [5, 6], poor uniformity [6, 7], fabrication complexity, high cost and low producibility yield while QWIPs suffers from low quantum efficiency, 11 12 lower operating temperature [8] and one-dimensional (1 D) carrier confinement which increases dark current making them unsuitable for high-temperature operation [9-11]. 13 14 Type-II superlattices (T2SL) have emerged as a promising alternative to MCT and QWIPs due to their flexible and more controllable band-gap engineering through the design of the SL 15 16 layer thickness/composition and coherency strain[12]. However, recent atom probe 17 tomography and X-ray energy dispersive spectrometry studies [13, 14] have demonstrated 18 that Ga-free InAs/InAsSb T2SL exhibit Sb segregation which could potentially induce undesirable effects on band-gap engineering including broadening of the optical response, 19 as well as weakened absorption[12]. Consequently, Ga-based InAs/GaSb T2SL infrared 20 21 material have attracted extensive research interest for photodetection due to their 22 potential to provide cheaper, high device performance at high temperature with 23 significantly reduced dark current[15] and high responsivity[11] resulting from large 24 absorption coefficient[16], reduced tunnelling currents[17] and reduced hole-hole auger

recombination due to the large splitting between the heavy-hole and the light-hole bands of
 the superlattice[18]. InAs/GaSb T2SL have been theoretically predicted[7, 19] to significantly
 outperform current state-of-the-art MCT.

There are limited reports[20, 21] of near room temperature photodetection using 4 5 InAs/GaSb SL within the 5.1 - 5.6 μ m spectra window for NO_x detection. Rogalski et al [20] achieved 50% cut-off wavelength of 5.2µm at 230 K on a T2SL InAs/GaSb mesa PIN 6 architecture using GaAs substrate converted into immersion lens for increased detectivity. 7 8 Krishna et al [21] obtained a cut off wavelength of 5.2µm at room temperature using a nBn structure based on InAs/GaSb T2SL. It is essential to further extend the detection limit of 9 10 InAs/GaSb T2SL towards 5.5µm at near room temperature. More so, there is very limited detailed investigation [22] of the temperature-dependent PL investigation of InAs/GaAs SL 11 12 as such there is a need for further research activities to better understand the optical properties at higher operating temperature. In a previous study [23], we have investigated 13 14 the influence of the shutter sequence during the growth of InAs/GaSb SL on the structural, morphological and optical properties at 77K. In this study, we report the optical and 15 16 electrical characteristics of 5.5µm nip InAs/GaSb T2SL layers and photodiodes operating up 17 to 300K.

18

19 Experimental method

1 To investigate the optical properties of MWIR Ga-based T2SLs, two InAs/GaSb SL samples were grown by molecular beam epitaxy (MBE) at optimized condition[20]. Sample A was 2 grown with an intentional InSb layer grown using migration enhanced epitaxy (MEE) at both 3 interfaces while sample B was grown using an antimony-for-arsenic exchange at the GaSb-4 5 on-InAs IF leading to an 'InSb-like' interfaces (IFs). Figure 1 shows the schematic diagrams of More details of the growth method of these samples can be found 6 the samples. 7 elsewhere[23]. Both samples were grown on GaSb substrates with GaSb buffer layers and thicknesses of 50 nm. The samples consist of 100 periods of a superlattice with the 8 asymmetrical layer thicknesses of 7 MLs of InAs and 4 MLs of GaSb in every single period. 9 10 Both samples were then capped with 1.2 nm of GaSb layers. Growth details of the Ga-free InAs/InAsSb SL reference (sample C) could be found elsewhere [25, 26]. The optical 11 characteristics of both samples were investigated by PL measurements at different 12 temperatures from 77 K to 293 K. A Nicolet iS50R Fourier Transform Infrared (FTIR) 13 14 Spectrometer was used to acquire PL signal from the samples. The samples were loaded into 15 а



Figure 1. A schematic diagram shows the Ga-based T2SL samples grown by MBE using (a) MEE method (sample A) and (b) As-Sb exchange growth technique (sample B) and used to undertake PL measurements.

1 cryostat supplied with CaF₂ windows to perform temperature-dependent PL measurements 2 using liquid nitrogen. A laser diode with a wavelength of 785 nm was used as an excitation source and the excitation power of the laser was fixed to ~50 mW. A cooled MCT detector 3 with a high detectivity was utilised as a detector source for the PL signal. A nip photodiode 4 5 with an intrinsic region similar to sample B was grown using the same growth conditions described above. Photodiodes were fabricated using a standard photolithography process. 6 Cr/Au contacts were evaporated onto the top and bottom of the sample and a citric acid-7 based wet etch was used to define 90 to 440 µm diameter mesas. Photoresist protection 8 was used to block the mesa sidewalls from ambient air. A schematic of a fabricated nip 9 10 detector, and the current path therein, is shown in Figure 2. Liquid nitrogen cooled cryogenic probe station was then used to perform current-voltage measurements on a 11 140 µm diode. 12



13

14

Figure 2: A schematic representation of a fabricated nip diode. Blue arrows highlight the flow of electrons.

1 Results and discussion

Material characterization, including X-ray diffraction (XRD) $\omega/2\theta$ scans and Atomic Force Microscopy (AFM), were performed for Samples A and B and reported in a previous work [23]. Sample A was found to be under slight compressive strain, indicating the total thickness of the InSb IFs is too large. The SL layers of Sample B were found to be almost lattice matched onto the GaSb substrate. The slight lattice mismatch in Sample B may have led to a minor degradation in material quality which is corroborated by a slightly larger XRD FWHM and rms roughness as measured by AFM.

Figure 3 shows the temperature-dependent PL spectra of the Ga-based samples. At 77 K, 9 10 the dominant PL peak energies are positioned at around 5.3µm, for both samples [5.5µm] (225meV) and 5.1 µm (243meV) for samples A and B respectively]. This dominant PL peak is 11 associated with the SL transition energy from the first electron miniband to the heavy hole 12 13 miniband (e₁-hh₁). The observed redshift in the peak position of sample A relative to B is attributed to the presence of the relatively thick InSb IF layer at the SL interfaces of sample 14 A [23] which contributes to a decrease in PL peak energy consistent with a previous study 15 16 [27]. The 50% cut-off wavelength at 77 K for each sample, here defined as the energy value of the negative slope of the PL profile at half maximum intensity, was measured to be 0.240 17 18 eV and 0.259 eV for Samples A and B, respectively. These measurements confirm the 19 suitability of the T2SLs for NO_x sensing applications.



1

2 Figure 3. Normalized temperature dependant PL spectra of both Samples A and B.

Excitons are thermally excited from the first miniband electrons to the conduction band of the InSb-like interfaces to recombine non-radiatively [28, 29]. A redshift of 22 and 19 meV with increasing temperature from 77 to 293 K was obtained for samples A and B respectively. As expected, the PL peak intensity of both samples decreases with increasing temperature.

A Gaussian fitting analysis was used to extract the band energy from Figure 3 as a function
of temperature, the results are shown in Figure 4(a). The temperature dependant behaviour
of the band energy was fitted using the well-known Varshni equation[30]:

11
$$E_g(T) = E_g(0K) - \frac{\alpha T^2}{\beta + T'}$$
 (1)

12 Where E_g is the band gap energy, T is the temperature and α and β are fitting parameters. 13 The value of β was fixed at 270 K in accordance with a previous report[31]. The α values

were thusly determined to be 0.162 meV and 0.171 meV for Samples A and B, respectively, 1 2 which is close to that of a previously reported MWIR InAs/GaSb T2SL detector[32]. The integrated PL intensities of the samples are compared to that of a reference Ga- free, 3 InAs/InAsSb T2SLs (sample C) as shown in Figure 4(b). Gradients of (3.22± 1.92, 3.67± 2.45 4 and 6.00± 7.83) x 10⁻³ for samples A, B and C respectively were extracted. The gradient of 5 the Ga-free SL almost twice that of the Ga-based one for similar temperature regime which 6 indicates that the two Ga-based samples are less sensitive to temperature than the Ga-free 7 SL reference sample C. The relatively low rate of quenching of the Ga-based samples could 8 be related to the presence of fewer non-radiative defects centres corresponding to a lower 9 10 rate of thermal quenching[33]. In addition, compared to the rapid thermal quenching of the PL intensity of sample B, sample A is less sensitive to temperature changes with its PL 11 intensity quenched by only about half of that of sample B for changes in temperature in the 12 interval 77 - 293 K (see also Figure 3) which suggests the presence of more non-radiative 13 recombination centres in sample B. This demonstrates the superior optical property of 14 sample A grown with an intentional InSb layer compared to sample B in good agreement 15 16 with a previous study 34 and attributed to the smoother surface at the interface.



Figure 4. (a) The measured band energy for Samples A and B as a function of

2 temperature, fitted using the Varshni equation. (b) Temperature dependant 3 integrated PL intensity for Samples A, B, and C. 4 The 8-band k·p envelope-function method implemented in the Nextnano3 software [35] was employed to model the band structure of the 7 ML InAs/4 ML GaSb T2SL which is depicted in 5 Figure 5. (Details of the parameters used can be found elsewhere[36]). It should be noted that 6 7 Sample A was modelled as having an InSb interfacial layer at both IFs while Sample B was modelled as having an InSb layer at the GaSb-on-InAs layer and a sharp IF at the InAs-on-8 GaSb IF. Interestingly, the calculated energy gap of 225meV for sample A is consistent with 9 that predicted by the PL result and redshifted with respect to the simulated band energy of 10 11 Sample B (237meV), as earlier demonstrated by PL result, but is slightly off the measured 12 band energy.

13



Figure 5: (a) Schematic diagram of the simulated band structure of the 7/4 SL for samples A and B (a-b) respectively. The electronic band structure of a 7/4 SL calculated at T = 77K for two in-plane directions in the Brillouin zone for sample A and B (c-d) respectively.

This can be attributed to the uncertainty of the composition of the IFs, particularly the InAson-GaSb IF. This further indicates that the band energy of the InAs/GaAs SL could be tuned to longer wavelength with the insertion of InSb layer at both interfaces. The electronic band structure of the 7/4 SL calculated at T = 77K for two in-plane directions in the Brillouin zone for samples A and B are shown in Figure 4c-d, respectively.

Figure 6a shows the temperature-dependent current density characteristics of the nip
photodetectors at 110 K, 200 K and 300 K. As expected, the dark current density increases



Figure 6: (a) Measured dark current density vs applied bias characteristics of the photodetectors at temperatures 110, 200, and 300 K. Modelled dark current density under applied bias at temperatures of (b) 110 K, (c) 200 K, (d) 300 K.

from 5.35x 10⁻⁵ to 8.541 A/cm² as the temperature was increased from 110 to 300 K. The modelled dark current density under reverse bias at different temperatures is shown in **Figures 6 b-d**. The dark current in a T2SLs diode has been accurately modelled by Gopal et al. [37-38] to be the sum of diffusion, trap assisted tunnelling (TAT), shunt and generationrecombination (G-R) current. Diffusion current refers to the diffusion of minority carriers from high to low concentrations and can be modelled as:

7
$$I_{diff} = \frac{qAn_i^2}{N_d} \left\{ \frac{kT}{q} \frac{\mu_h}{\tau_h} \right\}^{1/2} \tanh \frac{d}{L_h} \left[\exp\left(\frac{qV}{kT}\right) - 1 \right], \tag{1}$$

8 where N_d is the donor concentration, n_i is the intrinsic carrier concentration, A is the 9 junction area, V is the diode bias voltage, d is the thickness of the n region, τ_h is the hole 10 lifetime, μ_h is the hole mobility and L_h is the hole diffusion length. G-R current is related to 11 defects in the depletion region acting as Shockley-Read-Hall (SRH) recombination centres. 12 For reverse bias, considered above, the G-R current can be given by:

13
$$I_{G-R} = \frac{qAn_i W_{dep} V}{V_t \tau_{G-R}},$$
 (2)

14
$$A_{G-R} = \frac{qn_t A}{2\tau_{G-R}} \left[\frac{2\varepsilon_0 \varepsilon_s (N_a + N_d)}{qN_a N_d} \right]^{1/2}$$
, (3)

15

where τ_{G-R} is the G-R lifetime, N_a is the acceptor concentration and W_{dep} is the depletion region width. The TAT current originates from mid-gap trap states which carriers can use to tunnel between bands, usually under a high electric field, and is expressed as:

19
$$I_{TAT} = \frac{\pi^2 q^2 A m_e V_t M^2 N_T}{h^3 (E_g - E_t)} \times \exp\left\{-\frac{8\pi (2m_e)^{1/2} (E_g - E_t)^{3/2}}{[3qhF(V)]}\right\},$$
 (4)

where m_e is the tunnelling effective mass, E_g is the superlattice bandgap, h is Planck's constant, M is the matrix element associated with the trap potential, F(V) is the voltage

dependant electric field strength across the depletion region, E_t is the location of the trap
level below the conduction band edge, N_T is the trap density. Ohmic shunt currents are
usually caused by native oxides, formed on the mesa sidewalls during etching, which act as
good conductors. This component can simply be described using Ohm's law:

$$5 I_{sh} = \frac{V}{R_{sh}}, (5)$$

where R_{sh} is the diode shunt resistance. Due to the limited shielding of the probe station, a 6 measurement temperature of 110 K was chosen to negate the effect of photocurrent. This 7 model fits the data well except for a small deviation at high bias which can be attributed to 8 the band-to-band tunnelling current not considered here. Figure 6b shows that at a 9 relatively low temperature of 110K, G-R current is dominant at low applied bias, but TAT 10 11 current dominates when the bias is increased above ~0.2 V. However, at higher operating 12 temperatures of 200 and 300 K, the contribution of diffusion current becomes dominant at low applied bias ~50 mV while G-R and TAT dominate the current at bias above ~0.2 V. This 13 result is consistent with results of similar devices which are G-R limited at low temperatures 14 15 [40, 41]. The significant contribution of the shunt current can be attributed to the lack of 16 passivation.

17 Conclusion

In this paper, the optical properties of the two grown Ga-based InAs/GaSb T2SL samples were explored using temperature-dependent photoluminescence measurements. It has been shown that incorporation of intentional InSb layers at the interfaces between InAs and GaSb SL layers for sample A results in a redshift in the PL wavelengths compared to sample B. Also, it has been shown that sample A is much less sensitive to temperature changes with

1 its PL intensities quenched by only about half of that of sample B for changes in temperature in the interval 77 - 293 K. To examine the electrical performance of the 2 3 fabricated *nip* photodiodes, I-V measurements were carried out and modelled at 110, 200 and 300K. From the JV modelling, it has been shown that G-R mechanism is the main source 4 5 of dark current at low reverse bias, while TAT is dominant at an applied bias above ~0.2 V. However, at higher operating temperature (200 -300 K), diffusion current is prevalent at low 6 7 applied bias while G-R and TAT dominate for high applied bias. Also, the shunt current has a considerable contribution to the dark current over the whole applied bias range which could 8 be attributed to the lack of surface passivation. This study demonstrates that InAs/GaSb 9 10 Type-II superlattice are highly promising for NOx sensing at around 5 µm. However, the optical and electrical properties of the InAs/GaSb T2SL could be further improved by 11 applying surface passivation processes to minimize the contribution of G-R dark current and 12 enhance the overall dark current of the photodiodes. 13

- 14
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Author's Statement

- We the undersigned declare that this manuscript is original, has not been published before and isnot currently being considered for publication elsewhere.
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- 9 **Declaration of interests**
- 10

40

- 11 I The authors declare that they have no known competing financial interests or personal
- 12 relationships that could have appeared to influence the work reported in this paper.

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